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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/808,059	03/24/2004	Leonard Forbes	400.285US01	4221
27073	7590 08/09/2005		EXAM	INER
LEFFERT JAY & POLGLAZE, P.A.			PIZARRO CRESPO, MARCOS D	
P.O. BOX 581009 MINNEAPOLIS, MN 55458-1009			ART UNIT	PAPER NUMBER
Will Will Ox	310, 11111 00 100 1003		2814	

DATE MAILED: 08/09/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		$\mathcal{A}_{\mathcal{K}}$
	Application No.	Applicant(s)
Office Action Summany	10/808,059	FORBES, LEONARD
Office Action Summary	Examiner	Art Unit
The MAU INC DATE of this communication	Marcos D. Pizarro-Crespo	2814
The MAILING DATE of this communication appeared for Reply	ppears on the cover sheet with the	correspondence address
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory perio - Failure to reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	I. 1.136(a). In no event, however, may a reply be a ply within the statutory minimum of thirty (30) da d will apply and will expire SIX (6) MONTHS fro ute, cause the application to become ABANDON	nimely filed ays will be considered timely. In the mailing date of this communication. IED (35 U.S.C. § 133).
Status		
1)	nis action is non-final. vance except for formal matters, p	
Disposition of Claims		
4) ⊠ Claim(s) 1-37 and 48 is/are pending in the ap 4a) Of the above claim(s) 3,8-37 and 48 is/are 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1,2 and 4-7 is/are rejected. 7) □ Claim(s) is/are objected to. 8) ⊠ Claim(s) 1-37 and 48 are subject to restriction	e withdrawn from consideration.	
Application Papers		
9) The specification is objected to by the Examin 10) The drawing(s) filed on 24 March 2004 is/are Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the I	: a)⊠ accepted or b)☐ objected ne drawing(s) be held in abeyance. S ection is required if the drawing(s) is c	ee 37 CFR 1.85(a). bjected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority application from the International Bure * See the attached detailed Office action for a list	nts have been received. nts have been received in Applica iority documents have been recei au (PCT Rule 17.2(a)).	ntion No ved in this National Stage
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date 6/3/2005.	4) Interview Summa Paper No(s)/Mail 5) Notice of Informal 6) Other:	ry (PTO-413) Date Patent Application (PTO-152)

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Attorney's Docket Number: 400.285US01

Filing Date: 3/24/2004

Claimed Foreign Priority Date: none

Applicant(s): Forbes

Examiner: Marcos D. Pizarro-Crespo

DETAILED ACTION

This Office action responds to the election filed on 7/28/2005.

Election/Restrictions

1. Applicant's election without traverse of claims 1, 2, and 4-7 in the reply filed on 7/28/2005 is acknowledged. Claims 3, 8-37, and 48 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim.

Acknowledgment

2. The amendment filed on 7/5/2005 responding to the Office action mailed on 6/13/2005 has been entered. The present Office action is made with all the suggested amendments being fully considered. Accordingly, pending in this Office action are claims 1-37 and 48.

Claims Rejection

3. Initially, and with respect to claims 1, 2, and 4-7, note that a "product by process" claim is directed to the product *per se*, no matter how actually made. See *In re Thorpe*, 227 USPQ 964 (CAFC, 1985) and the related case law cited therein which makes it clear that it is the final product *per se* which must be determined in a "product by

process" claim, and not the patentability of the process, and that, as here, an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. As stated in Thorpe,

even though product-by-process claims are limited by and defined by the process, determination of patentability is based on the product itself. *In re Brown*, 459 F.2d 531, 535, 173 USPQ 685, 688 (CCPA 1972); *In re Pilkington*, 411 F.2d 1345, 1348, 162 USPQ 145, 147 (CCPA 1969); *Buono v. Yankee Maid Dress Corp.*, 77 F.2d 274, 279, 26 USPQ 57, 61 (2d. Cir. 1935).

Note that the applicants have the burden of proof in such cases, as the above case law makes clear.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 1, 2, and 5-7 are rejected under 35 U.S.C. 103(a) as being unpatentable over She in view of Chang (US 2002/0086548).
- 6. Regarding claim 1, She shows (see, e.g., fig. 1) all aspects of the instant invention including an NROM memory transistor comprising:
 - ✓ A substrate
 - ✓ A plurality of source/drain regions in the substrate

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- ✓ A nanolaminate, high permittivity (high-k), metal-gate dielectric having a dielectric constant greater than that of silicon dioxide (see, e.g., pp.53/col.1/II.39-42)
- ✓ A control gate on top of the gate dielectric wherein the conductivity type of the source/drain regions is different than that of the reminder of the substrate.
- 7. Regarding claim 2, She shows the gate dielectric is a composite oxide -- high-k dielectric oxide nanolaminate gate insulator wherein the high-k dielectric is a charge-trapping layer (see, e.g., pp.53/col.1/II.1-7).
- 8. Regarding claim 5, She shows the charge-trapping layer comprising a material that has a lower conduction band edge than silicon nitride (see, *e.g.*, pp.53/col.1/II.35-43).
- 9. Regarding claim 6, She shows the gate dielectric having a larger energy barrier between the high-k dielectric and the oxide insulator than silicon dioxide (see, e.g., pp.53/col.1/II.45-48).
- 10. Regarding claim 7, She shows the gate dielectric has an oxide-Hf oxide-oxide structure (see, *e.g.*, fig. 1).
- 11. Regarding claims 1, 2, and 7, it is noted that She shows all aspects of the semiconductor device according to the claimed invention (see, e.g., paragraphs 6 and 7 above) and that the method of forming the insulating film by the low-temperature oxidation of a metal, is an intermediate step that does not affect the structure of the final device.

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In spite of the above, Chang (see, e.g., par. 0029) uses a low-temperature oxidation step to form a gate dielectric similar to She to reduce the thermal budget of its manufacturing. This will improve the reliability of She's flash memory transistor.

Accordingly, it would have been obvious at the time of the invention to one of ordinary skill in the art to form She's gate dielectric using the low-temperature oxidation of a metal, as suggested by Chang, to improve the reliability of the transistor.

- 12. Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over She/Chang in view of Akatsu (US 5717635).
- 13. Regarding claim 4, She shows most aspects of the instant invention (see, e.g., paragraph 6 above). She, however, fails to show that the transistor is in either a NOR-type flash memory structure of a NAND-type flash memory structure. She, however, teaches that the transistor is a flash-EEPROM device (see, e.g., abstract). At the present time, there are two basic architectures for EEPROM memory cell arrays referred to as NOR-type and NAND-type respectively (see, e.g., Akatsu/col.4/II.50-57). The NAND-type, however, lends itself to much higher integration densities (see, e.g., Akatsu/col.5/II.34-40).

It would have been obvious at the time of the invention to one of ordinary skill in the art to have She/Chang's transistor in a NAND-type memory structure, as suggested by Akatsu, to achieve a high-integration density.

Conclusion

14. Papers related to this application may be submitted directly to Art Unit 2814 by facsimile transmission. Papers should be faxed to Art Unit 2814 via the Art Unit 2814

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Fax Center. The faxing of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (15 November 1989). The Art Unit 2814 Fax Center number is (571) 273-8300. The Art Unit 2814 Fax Center is to be used only for papers related to Art Unit 2814 applications.

- 15. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Marcos D. Pizarro-Crespo at (571) 272-1716 and between the hours of 9:30 AM to 8:00 PM (Eastern Standard Time) Monday through Thursday or by e-mail via Marcos.Pizarro@uspto.gov. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy, can be reached on (571) 272-1705.
- 16. Any inquiry of a general nature or relating to the status of this application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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17. The following list is the Examiner's field of search for the present Office Action:

Field of Search	Date
U.S. Class / Subclass(es): 257/314,324-326,410,411	8/4/2005
Other Documentation:	
Electronic Database(s): EAST (USPAT, EPO, JPO)	8/4/2005

Marcos D. Pizarrø-Crespo

Patent Examiner Art Unit 2814 571-272-1716

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MDP/mdp August 4, 2005